Electronic Supplementary Information

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Chemicals and materials

Phenol, formaldehyde solution (36.5~38 % in H₂O), niobium(V) ethoxide (Nb(OEt)₅), and tetrahydrofuran (THF) were purchased from Sigma-Aldrich. Sodium hydroxide (NaOH, bead) and concentrated HCl (35~37 %) were purchased from Samchun (Korea). Polystyrene-*b*-poly(ethyleneoixde) (PS-*b*-PEO) was synthesized by atomic transfer radical polymerization (ATRP).¹ All of the chemicals were used without further purification.

Synthesis of phenolic resin (resol)

5g of Phenol (53 mmol) was melted at 40 °C in a flask and mixed slowly with 1.1g of 20 wt% NaOH aqueous solution (5.3 mmol) under stirring. After 10 min, 8.6g of formaldehyde solution (106 mmol) was added to phenol solution. The molar ratio of phenol:formaldehyde:NaOH was 1:2:0.1. The solution reacted at 70 °C for 1 h with stirring, and the solution was cooled room temperature. The mixture was neutralized using 2 M HCl. Water was removed under vacuum condition below 50 °C, and THF was poured into resol to precipitate NaCl produced during neutralization. After NaCl removal by filtration, THF was removed by vacuum evaporation below 50 °C.

Preparation of functional macrodomain-embedded mesoporous Nb₂O₅ (FM-Nb₂O₅)

In a typical synthesis of FM-Nb₂O₅, 0.2 g of PS-*b*-PEO (34.6 kg/mol, 14.4 wt% of PEO, PDI of 1.39) was dissolved in 6 mL of THF, and 0.73 g of 20 wt% resol solution in THF was added into the polymeric solution. 0.55 g of Nb(OEt)₅ was added into the mixture under stirring. After 10 min, 0.44 g of concentrated HCl(35~37 wt%) was added dropwise to suppress formation of large size oligomers. After stirring for 1 h, the obtained clear solution was poured into a petri dish to evaporate THF and HCl slowly at 40 °C for 24 h, followed by sequential heating at 100 °C for 24 h in an oven. The as-made product was carbonized at 700 °C under Ar for 2 h with a heating rate of 1 °C min⁻¹, and subsequently heated at 450 °C under air for 5 h to remove carbon.

Preparation of mesoporous Nb₂O₅ (m-Nb₂O₅)

It was prepared using the same procedures for preparation of FM-Nb₂O₅ without resol. 0.2 g of PS-*b*-PEO was dissolved in 6 ml of THF. 0.88 g of Nb(OEt)₅ and 0.44 g of HCl were added in sequence. Since the mesostructure was affected by volume fraction of hydrophilic block,

Nb(OEt)₅ was added more instead of resol to prepare 2D-hexagonal structure. The remaining procedures are identical with those for FM-Nb₂O₅

Fabrication of Dye sensitized solar cell

For working electrodes of DSSCs, screen-printable paste was prepared by mixing 0.2 g FM-Nb₂O₅ power (or m-Nb₂O₅) with 0.175 g of binder solution (5 wt% ethyl cellulose dissolved in α -terpineol). The highly viscous paste was diluted by adding 0.13 g of α -terpineol and then thoroughly mixed. The obtained paste was deposited onto FTO glass using a doctor blade technique, followed by annealing at 500 °C for 30 min under air. The working electrodes were immersed in an ethanol solution containing 0.5 mM cis-bis(isothiocyanato)bis(2,2'-bipyridyl-4,4'-dicarboxylato)ruthenium(II) bis-tetrabutylammonium (N719, Everlight) for 24 h. A platinum (Pt) counter electrode was prepared by dropping the 7 mM H₂PtCl₆·6H₂O in isopropanol and then annealing at 400 °C for 20 min. The working electrody was filled into the cell through hole drilled in the counter electrode. The electrolyte composed of 0.7 M 1-propyl-3-methylimidazolium iodide, 0.03 M I₂, 0.1 M guanidinium thiocyanate, and 0.5 M 4-tertbutylpyridine in a mixed solution of acetonitrile and valeronitrile (85:15 v/v).

Materials Characterization

Transmission electron microscopy (TEM) measurements were conducted on a JEOL JEM-1011 microscope operated at 200 kV. The samples for TEM measurements were microtomed and supported on Cu grids. Scanning electron microscopy (SEM) was performed on a Hitach S-4200 field emission SEM. Electron energy loss spectroscopy analysis was conducted on a JEOL JEM-2200FS transmission electron microscope. The small-angle X-ray scattering (SAXS) measurements were taken on a 4C SAXS beamline at the Pohang Light Source II. Powder X-ray diffraction (XRD) patterns were collected on a Bruker D8 Advanced X-ray diffractometer (Cu K α). Nitrogen physisorption isotherms were obtained at 77 K using a Micromeritics Tristar 3020 analyzer. Specific surface areas (S_{BET}) and pore diameter (D_P) were calculated by using BET and BJH models, respectively. The photocurrent–voltage (*J–V*) measurements were performed using a Keithly model 2400 source measurement unit. A class-A solar simulator (Yamashita Denso YSS-50A) was used and the light intensity was adjusted with an NREL-calibrated Si solar cell with KG-3 filter for AM 1.5G 1 sun light intensity. The *J-V* measurement was performed with an aperture mask to prevent extra light coming through the lateral space. The incident photon-to-current conversion efficiency (IPCE) was measured using a K3100 EQX spectral IPCE measurement system (PV Measurements, Inc.). The active area of cell was measured by an image analysis program equipped with a digital microscope camera (Moticam 1000) and the thickness of electrode film was measured by an Alphastep IQ surface profiler (KLA Tencor).

Reference

1 J. Hwang, J. Kim, E. Ramasamy, W. Choi, J. Lee, Microporous Mesoporous Mater. 2011, 143, 149



Fig S1. SEM images of FM-Nb₂O₅/C at difference length scales



Fig S2. (a) XRD pattern corresponding to orthorhombic Nb₂O₅, (b) SAXS pattern of FM-Nb₂O₅ and (c) N₂ physisorption isotherm with (inset) the pore size distribution of FM-Nb₂O₅



Fig S3. Structural characteristics of the mesoporous Nb₂O₅ (m-Nb₂O₅) synthesized without resol; SEM image after heat treatment (a) at 700 °C under Ar and (b) at 450 °C in the air, (c) SAXS pattern, (d) XRD pattern corresponding orthorhombic phase, and (e) N₂ physisorption isotherm, inset: pore size distribution.



Fig S4. Cross-sectional SEM images of (a) FM-Nb₂O₅, (b) m-Nb₂O₅, (c) m-TiO₂+FM-Nb₂O₅ and (d) m-TiO₂+SL-TiO₂ bilayer films. Insets are schematic representations of the four electrodes with different light pathway caused by light scattering effect.



Fig S5. Absorbance spectra of the solution containing the dye molecules detached from the films made of SL-TiO₂, m-Nb₂O₅ and FM-Nb₂O₅.

Sample	$V_{ m oc}$ (V)	$J_{\rm sc}$ (mA cm ⁻²)	FF	η (%)	Dye loading (× 10 ⁻⁸ mol cm ⁻² μm ⁻¹)
SL-TiO ₂	0.80	0.58	0.62	0.28	0.76
m-Nb ₂ O ₅	0.74	2.67	0.82	1.63	3.46
FM-Nb ₂ O ₅	0.73	4.57	0.82	2.75	4.48

Table S1. Photovoltaic characteristics and dye loading of SL-TiO₂, m-Nb₂O₅, and FM-Nb₂O₅ based DSSCs.



Fig S6. (a) IPCE spectra of DSSCs made from $FM-Nb_2O_5$, $m-Nb_2O_5$ and $SL-TiO_2$, (b) Normalized IPCE of (a) corresponding to $FM-Nb_2O_5$ and $m-Nb_2O_5$ based devices.



Fig S7. *J-V* curve of DSSC made with SL-TiO₂ WE with thickness of 12 μ m. Inset shows submicron large TiO₂ particles consisting the SL-TiO₂ film.



Fig S8. Diffuse reflectance spectra of the three films made of m-TiO₂ only, m-TiO₂+FM-Nb₂O₅, and m-TiO₂+SL-TiO₂ bilayer films before dye adsorption.



Fig S9. Optical images of (a) SL-TiO₂ and FM-Nb₂O₅ single films with same thickness of 12 μ m, (b) m-TiO₂+SL-TiO₂ and m-TiO₂+FM-Nb₂O₅ bilayer films after N719 dye adsorption. FM-Nb₂O₅ film showed deep purple color meaning the high loading of N719 dye due to its high surface area, while SL-TiO₂ film has very pale purple color nearly close to its pristine white film. The images of bilayers as shown in figure S9b highlight that upper FM-Nb₂O₅ layer plays roles in light absorption as well as light scattering, leading to improved light harvesting capability.

Sample	$V_{\rm oc}$ (V)	J _{sc} (mA cm ⁻²)	FF	η (%)
m-TiO ₂	0.75	12.96	0.71	6.95
m-TiO ₂ +SL-TiO ₂	0.75	14.24	0.71	7.56
m-TiO ₂ +FM-Nb ₂ O ₅	0.75	14.91	0.72	7.99

Table S2. Photovoltaic performances of DSSCs made of m-TiO₂ film only and m-TiO₂ with FM-Nb₂O₅ or SL-TiO₂ bilayer films.